

Fault Avoidance in Microelectronics by Pulsed Laser Irradiation

Joseph B. Bernstein

Materials and Nuclear Engineering Department
University of Maryland at College Park
2100 Marie Mount Hall phone : (301) 405-0357
email : joey@eng.umd.edu
www.enre.umd.edu/jb

OUTLINE

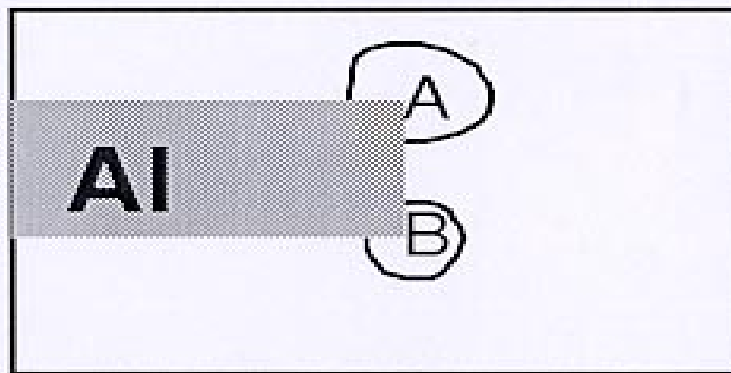
- Motivation
- Laser Cutting
- Laser Linking
- Future Research

EQUIPMENT

- XRL 525 Laser Processing System
 - 2 to 7 μm programmable elliptical spot
 - ≈ 100 laser operations per second
 - $\pm 1.0 \mu\text{m}$ positioning accuracy
 - $\pm 1\%$ energy delivered
- FEI Dual-Beam Focussed Ion-Beam tool
(Profs. Orloff and Melngailis in EE department)
- Karl Suss Automatic Wafer Probe Station
(Prof. Ramesh in NUMA)

Theory

- Stress in the Upper Corner is greater than in the lower corner

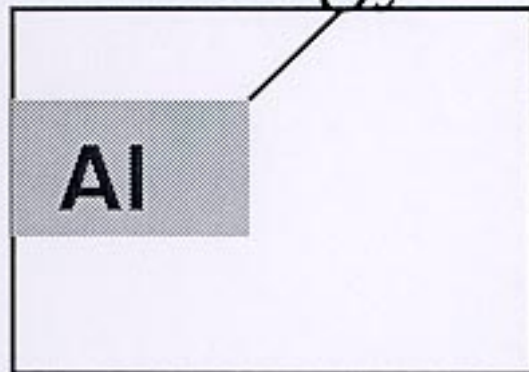


(cross-section)

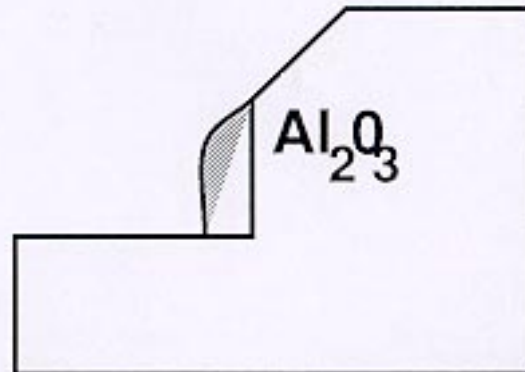
The Top fractures at a lower energy than the Bottom, thus removing the passivation

Laser Cut Evolution

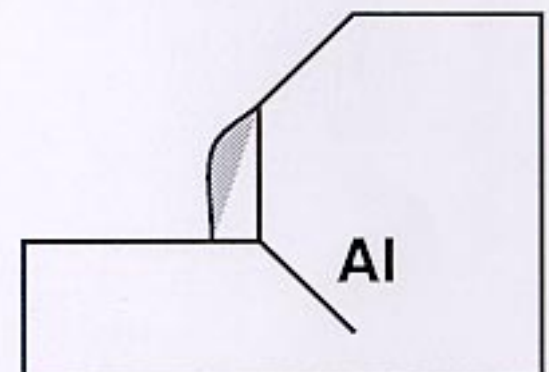
- Low Energy



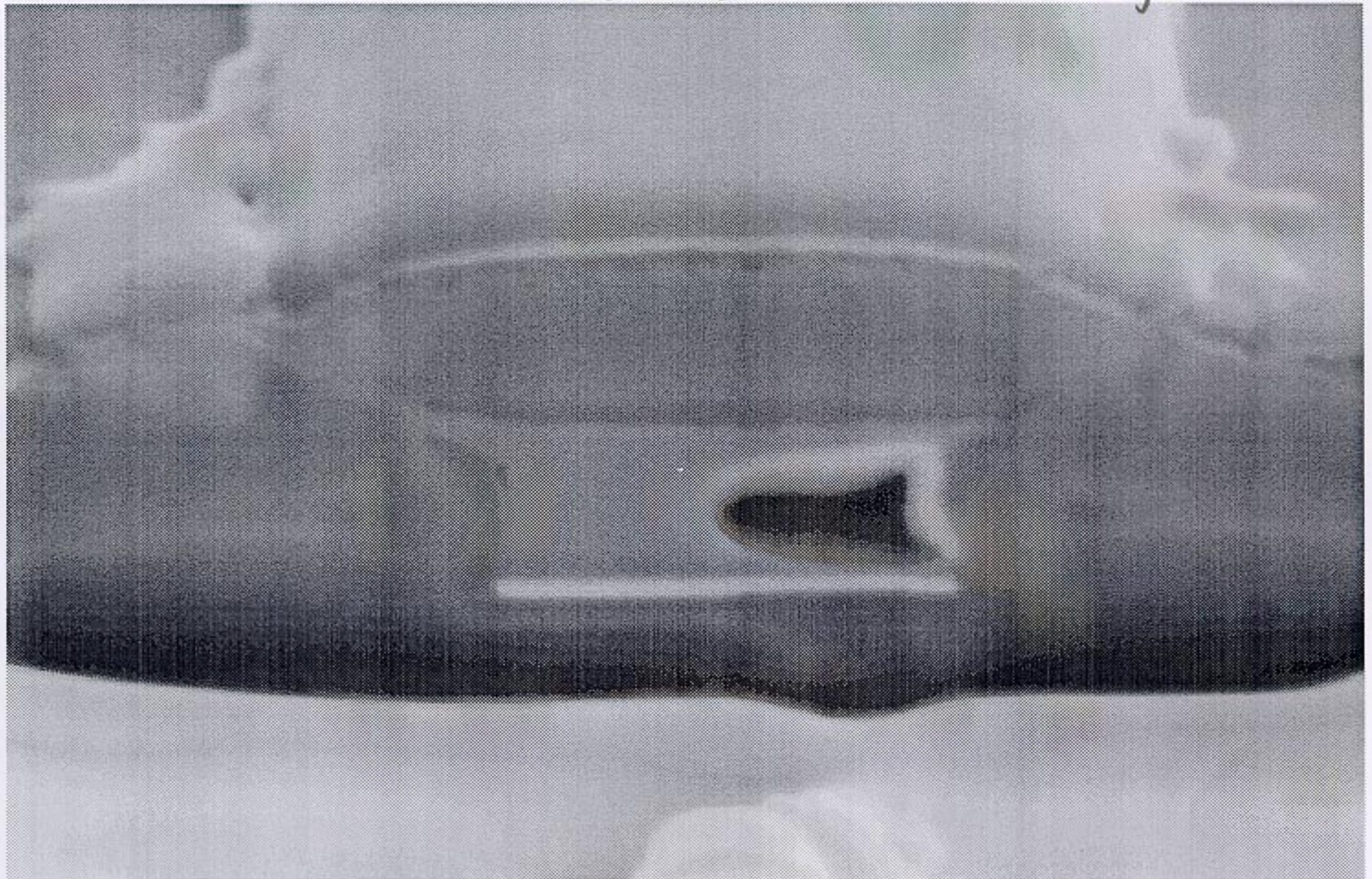
Ideal



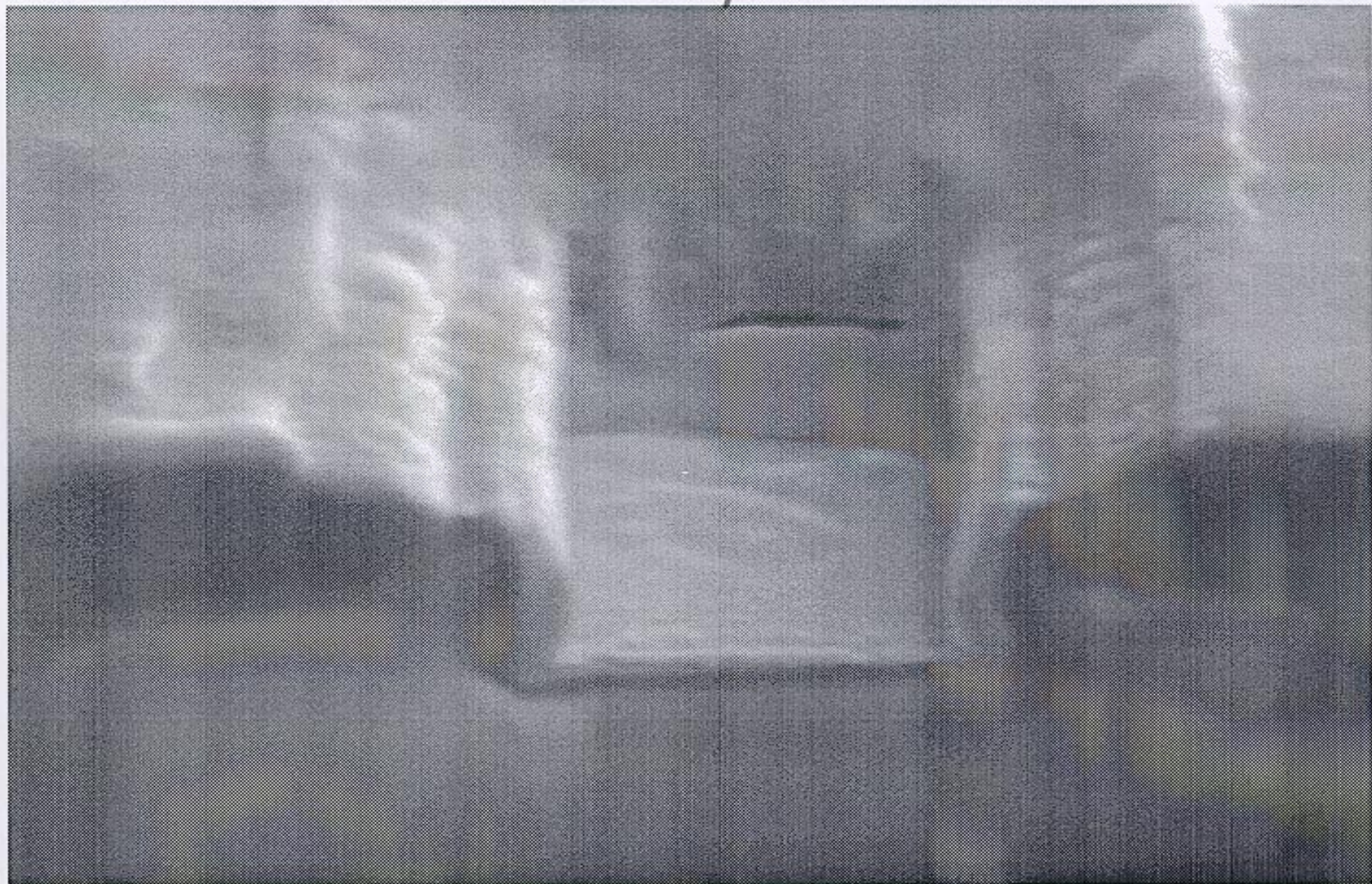
Too Much



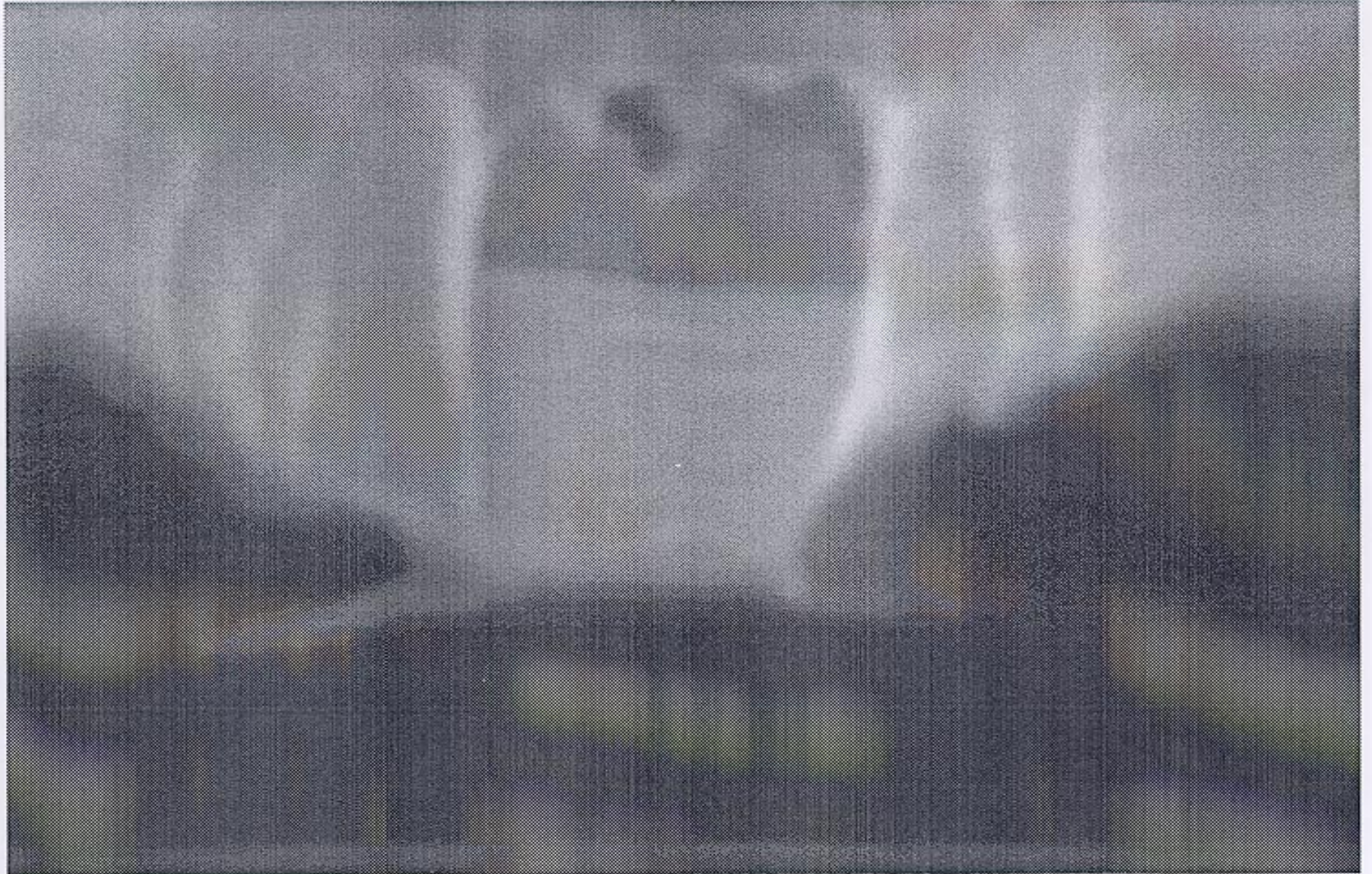
330 nJ : Medium Link Range



1.2 y5

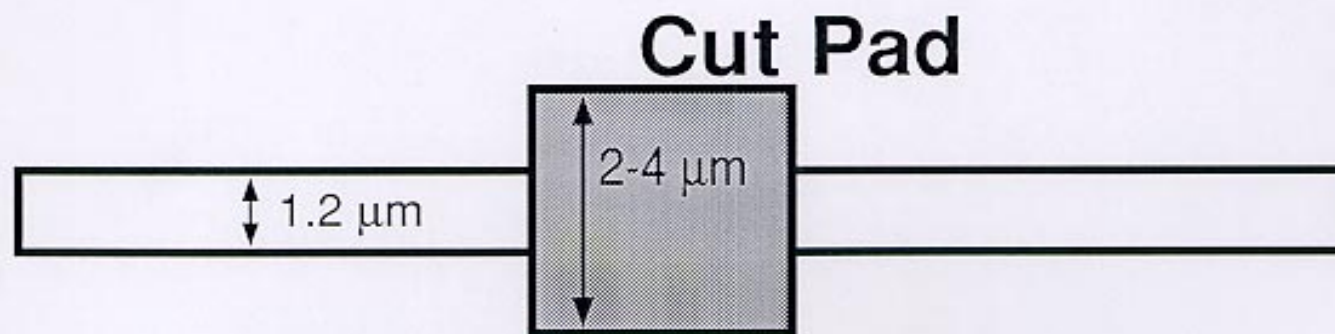


1.6 yJ : Lower Crude Forms



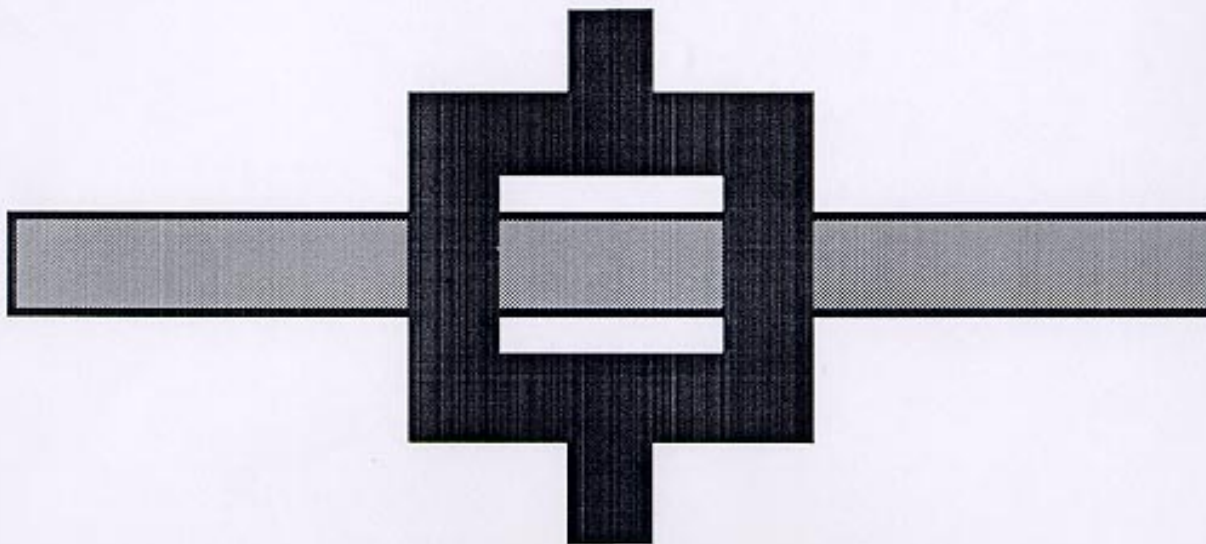
Proposed Cut Structure

- Wider metal for a more Reliable Cut
- Laser energy is absorbed where it is needed to cut the line
- Better removal of passivation



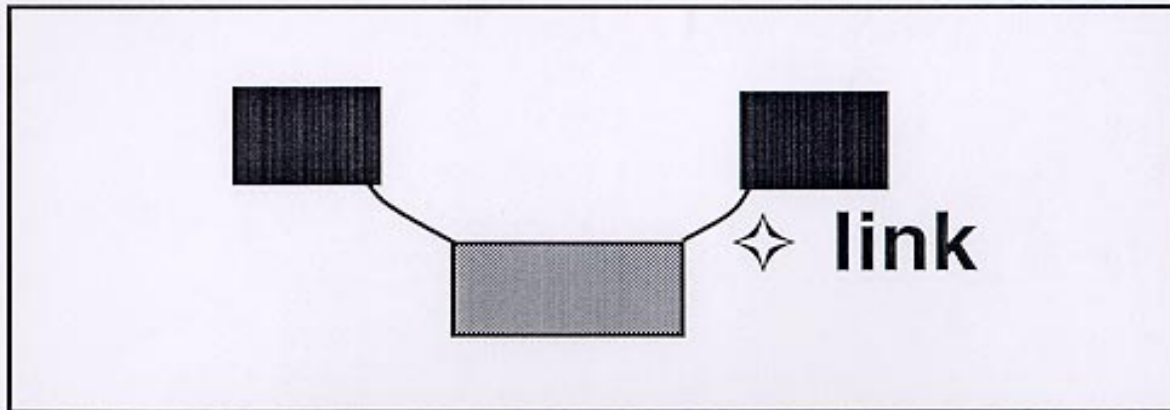
Improved Vertical Link

- Place Opening outside the edge of the lower metal



Advantages

- **Wider Energy Window**
- **Double Sided Redundancy**



- **Vertical Link Design included on JB051A test chip**

450 nJ Vertical Link with Round 2.2 μ m Spot

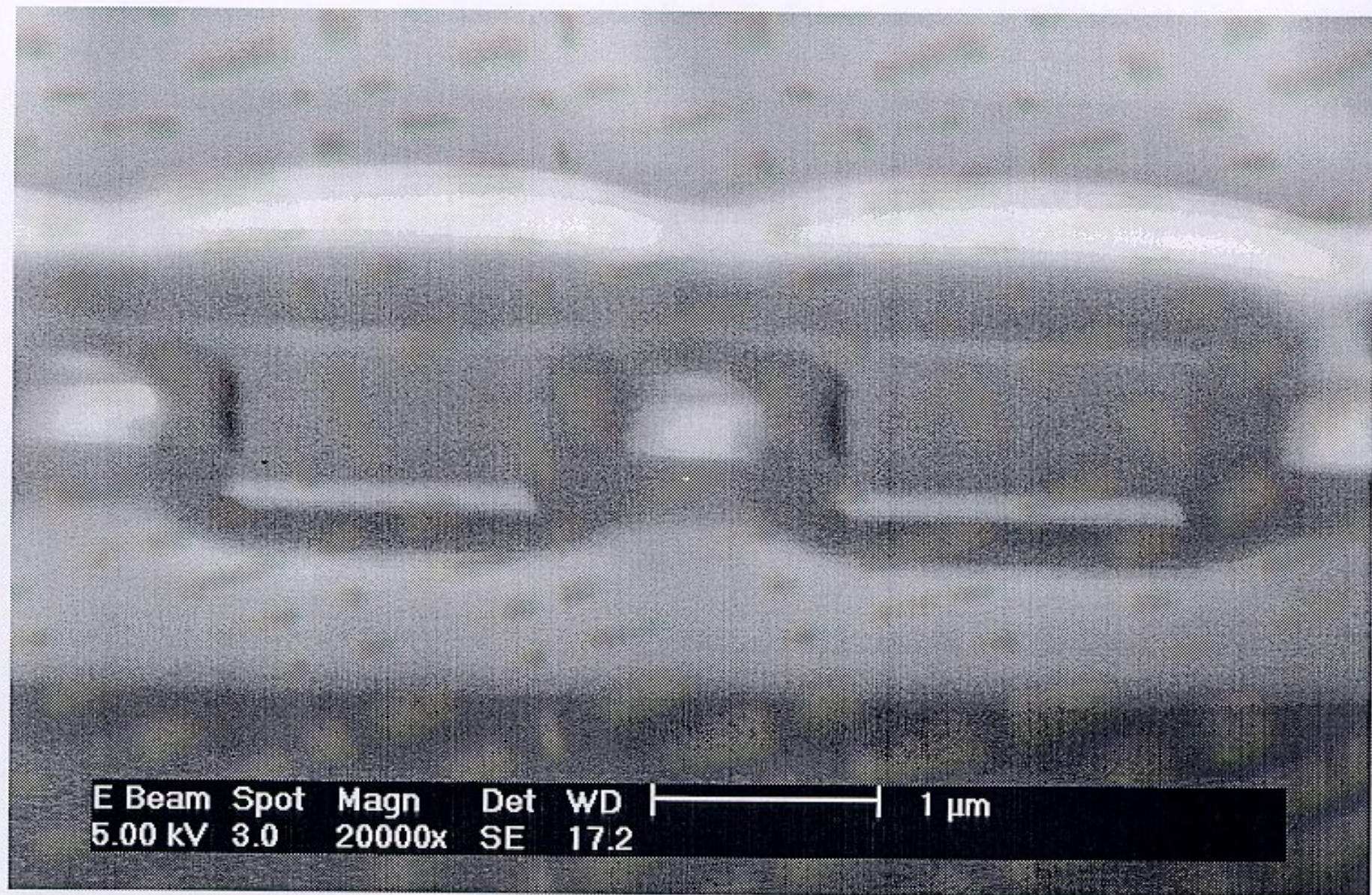
M2

M1 →

E Beam	Spot	Magn	Det	WD	1 μ m
5.00 kV	3.0	19972x	SE	17.3	

Advantages of Vertical Link

- NO Via Requirement
 - Link forms the via
- Self-Terminating Cracks
- Wider Process Window (with finer positioning accuracy)
- Scalable to MCM and WSI Dimensions



E Beam	Spot	Magn	Det	WD
5.00 kV	3.0	20000x	SE	17.2

1 μ m

Summary

- Confirmed New Cut-Failure
- Developed Fracture Criterion approach to laser links and cuts
- Used simulation to design new Link and Cut structures
- Proven Validity of Vertical Links
- Completed JB051A Test Chip

Future (FY-98)

- Develop Vertical Laser Links for WSI and MCM production
- Analyze the effects of process changes with respect to linking and cutting (CMP, W plugs, etc.)
- Maintain failure analysis for laser processing facility in R-141
- Develop new and innovative applications of laser processing